



INNOVATION

GaN devices for Industrial applications: opportunities and challenges

November 20, 2018

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Presentation plan

Proprieties of GaN devices and customer values

Interest of GaN devices for Industrial applications

Challenges

Conclusion

Proprieties of GaN devices and customer values

Low switching losses

Low conduction losses

High junction temperature

Bidirectional devices

Low cost potential



High efficiency

Low foot print

Competitive system cost

but lateral device, so normally limited to low power and low voltage (600V ?)

Power converters by Schneider Electric

Major products : Variable speed drive, UPS, PV inverter

Energy Storage



UPS
(Uninterruptible
Power Supply)



**Photovoltaic
inverter**
Renewable Energy



Active Filters
(Power Quality)



**Variable Speed
Drives**



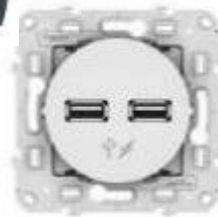
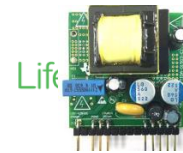
**Servomotor
drive**

Electrical Vehicle Charging



> View EVLink™ range

Power Supply



Interest of GaN devices for Industrial applications

GaN devices should find first implementation in small power applications.

Electrical Vehicle Charging



> View EVlink™ range

UPS (Uninterruptible Power Supply)



Photovoltaic inverter

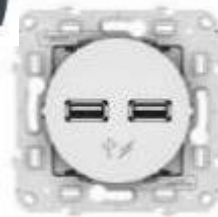
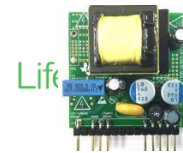


Variable Speed Drives



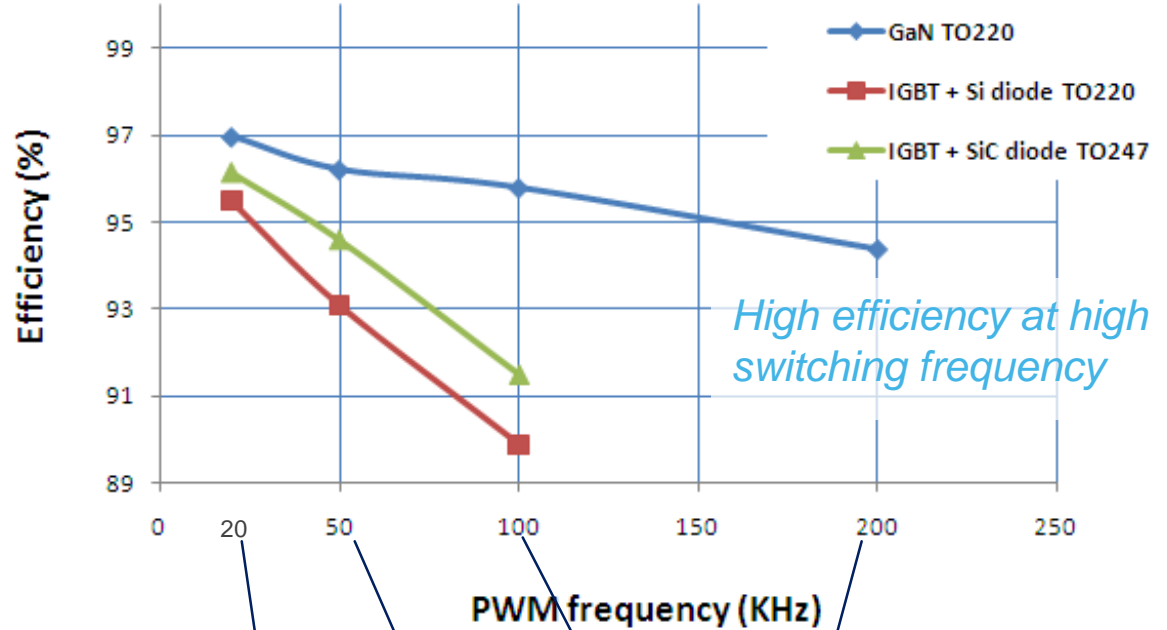
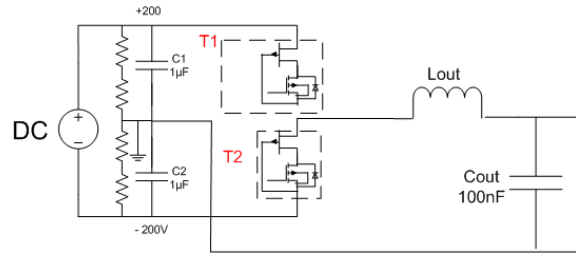
Servomotor drive

Power Supply

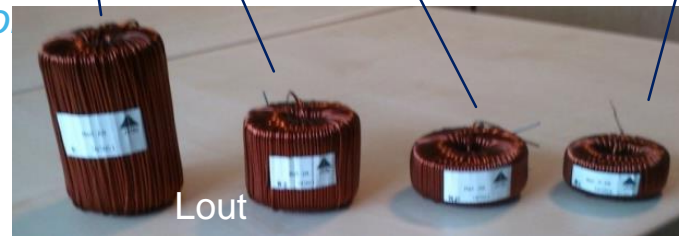


Experimental results confirm interest of GaN device

DC/AC inverter

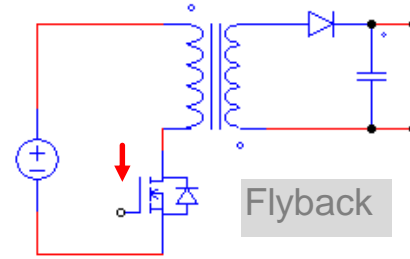
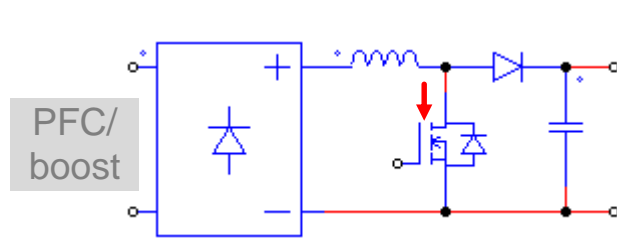


Reduction of size of inductor when switching frequency increase



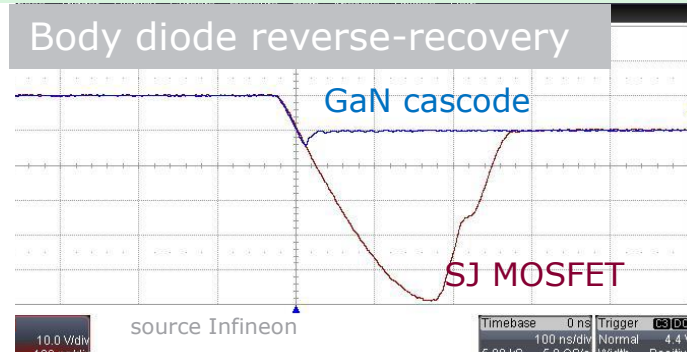
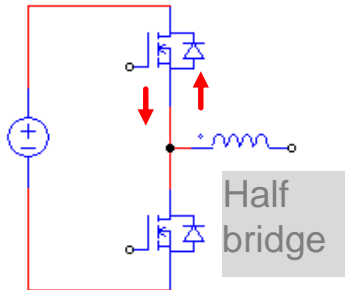
Challenges: positioning versus Superjunction MOSFET

Thanks to its fast switching and low conduction losses, SJ MOSFET is well adapted to PFC (power factor correction) and small power supply.

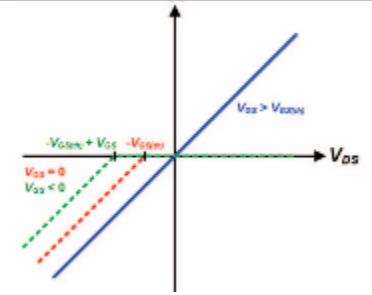


GaN could still bring some improvement, but quite limited on such topologies.

Due to its slow body diode, SJ MOSFET could hardly be used in half bridge topology. GaN should make difference with fast recovery and proper reverse conduction.



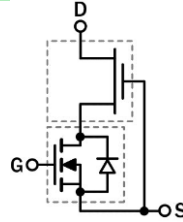
Reverse conduction versus V_{GS}



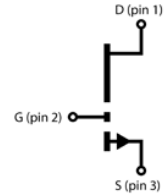
Challenges : Device types

Today, several device types are still in competition, each one with advantages and drawbacks

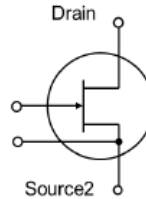
- *Depletion mode (Normally-on) & Cascode*



- *Enhancement mode (Normally-off)*



- *GIT (Gate Injection, Normally off)*



- *MIS (Metal Insulator Semiconductor)*

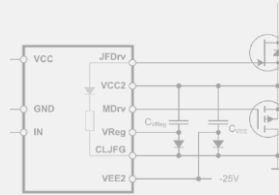
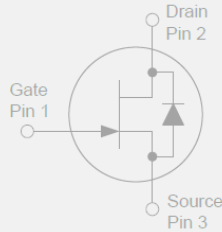
But device type diversity does not help industrial adoption.

Challenges : Comparative perspective with Convergence of SiC device types

Convergence of SiC device type happened just few years ago.

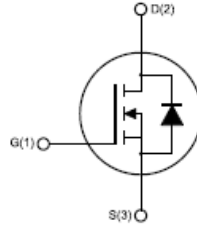
SiC JFET

- cascode
- dedicated driver



Cree
Semisouth
Infineon/SiCED
Hitachi
Toshiba

SiC MOSFET



ST
Infineon
Rohm
OnSemi
Wolfspeed

Cree
Fairchild
Mitsubishi
Philips
Rohm
GE

SiC BJT



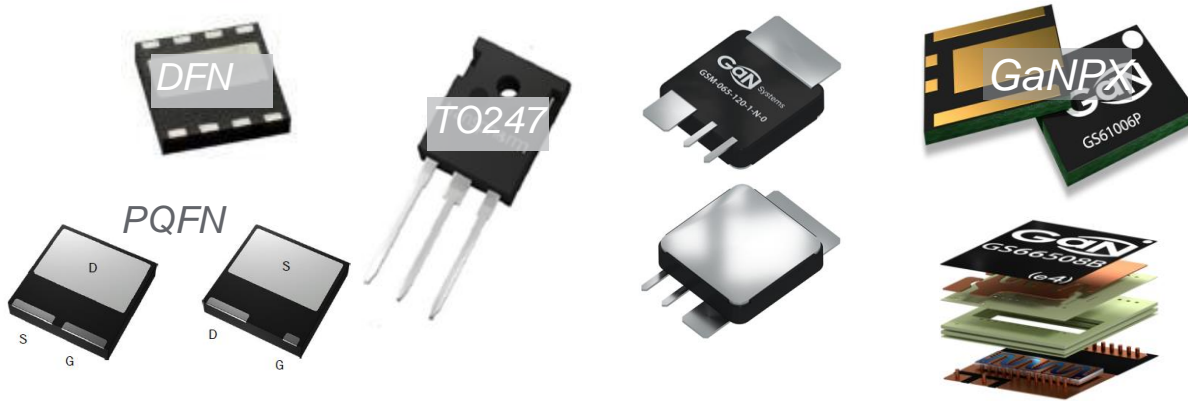
TranSiC
Cree

Life Is On

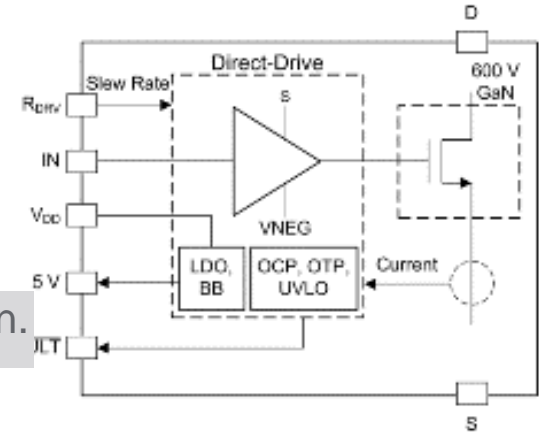
Challenges : diversity of packaging & integration

Faster than SiC, packaging and integration of GaN device are more important and challenging.

Today, there are multiple packagings (DFN, PQFN, TO220/TO247, GaNPX ...) as well as various integration levels (Switch-alone, Gate driver integration)



Gate driver + GaN

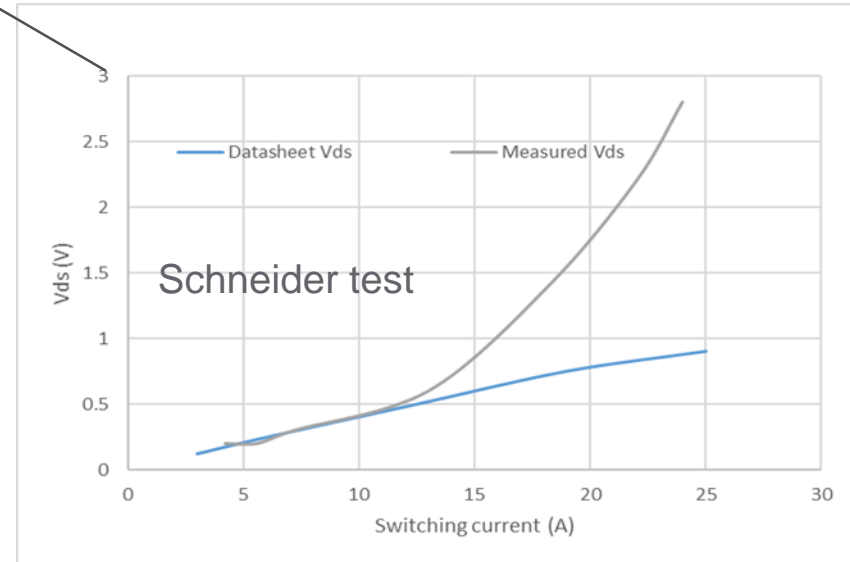
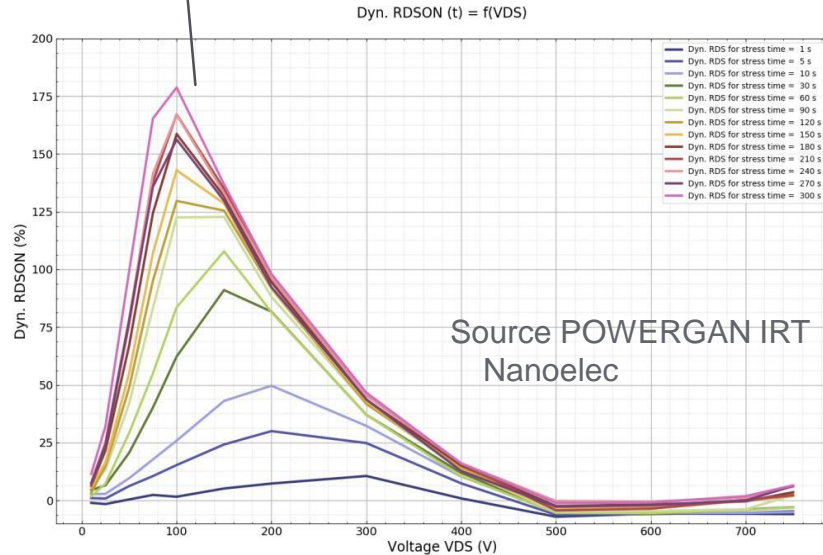


But packaging and integration diversity does not help industrial adoption.

Challenges : Reliability

GaN devices show still some particular behaviors such as :

- gate threshold voltage drift,
- charge trapping or current collapse (Rds_on temporary increase due to drain voltage in off state or due to gate voltage in reverse conduction).



Conclusion

*GaN is very promising technology with competitive cost potential.
First industrial applications in low voltage (<600V) and low power.*

Research effort should be focused on:

- *reverse conduction*
- *device type*
- *packaging & integration*
- *and reliability.*

Life Is On



Schneider
Electric

